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High-performance H₂S gas sensor utilizing MXene/MoS₂ heterostructure synthesized *via* the Langmuir–Blodgett technique and chemical vapor deposition†

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In this study, we developed an H₂S gas sensor based on a MXene/MoS₂ heterostructure, using the Langmuir–Blodgett (LB) technique and chemical vapor deposition (CVD). Ti₃C₂T_x MXene nanosheets were uniformly transferred onto SiO₂/Si substrates *via* the LB technique, achieving near-complete coverage. Subsequently, flower-like MoS₂ was grown on the MXene-coated substrate through CVD, with vertical growth observed on the MXene layers. Our hybrid sensors exhibited a significant enhancement in gas response, with the MXene/MoS₂ heterostructure showing a response of 0.5 to H₂S – approximately five times greater than that of pristine MXene. This improvement is attributed to the formation of a heterojunction, which increases electron mobility and reduces the depletion layer, enabling more efficient gas detection. Furthermore, the sensor demonstrated excellent selectivity for H₂S over other gases, including H₂, NO₂, NH₃, NO, and VOCs. The combination of the LB technique and CVD not only enhances gas sensor performance but also offers a promising strategy for synthesizing materials for various electrochemical applications.

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Introduction

Two-dimensional (2D) materials like graphene,^{1,2} phosphorene,^{3,4} metal–organic frameworks (MOFs),^{5,6} and MXene,^{7–9} known for their high surface-to-volume ratio, large surface area, and remarkable surface activities, have garnered significant attention for various applications. Among these, MXenes, represented by the formula M_{n+1}X_nT_x (where M denotes a transition metal like Ti, V, Cr, Mo, or Ta, X represents C or N, and T stands for surface terminal groups such as –O, –F, or –OH), are particularly notable for their high electrical conductivity,¹⁰ mechanical flexibility,^{11,12} tunable band gap,^{13,14} and large surface area.¹⁵ These properties make MXenes ideal for applications in sensors,^{16,17} energy storage systems, and electronic devices.^{18,19} However, MXene-based gas sensors encounter challenges such as low response, limited functional groups, low bandgaps, and reduced mechanical stability.^{20,21} To overcome these issues, surface functionalization of MXenes has emerged as a solution, enhancing chemical reactivity, tuning electronic

properties, and improving structural stability, unlocking the potential of MXenes in various technologies.^{22–24}

One approach to address these challenges is to incorporate materials like TMDs, metal oxides, and polymers onto the MXene surface. Recently, 2D semiconducting transition metal dichalcogenides (TMDs), with chemical formulas such as MX₂ (M = Mo, W; X = S, Se), have attracted great attention for their unique structural features and outstanding properties.^{25–27} In practice, NH₃ gas sensors using WS₂ synthesized through sulfuration *via* CVD have been studied, as well as H₂S gas sensors based on MoS₂ synthesized with rGO using the hydrothermal method.^{28,29} Among them, MoS₂ stands out, with a tunable bandgap that ranges from 1.8 eV in monolayer form to ~1.2 eV in bulk, making it suitable for a wide range of applications. MoS₂ also offers excellent carrier mobility, high surface area, mechanical strength, and flexibility due to the covalent bonding of Mo and S, making it highly desirable for sensors, photocatalysis, and energy storage.^{30,31} In particular, properties of MoS₂ make it ideal for various-type sensor applications when combined with MXene in heterostructures.^{32–34} Recent studies have successfully fabricated MXene/MoS₂ heterostructures using methods such as hydrothermal synthesis and sonication, applying them to reactive gas sensors.^{35,36}

In this study, we utilized the LB technique to deposit a monolayer of uniform Ti₃C₂T_x MXene nanosheets onto a substrate, optimizing their arrangement by controlling

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packing density. For densely packed MXene layers, defects such as overlapping nanosheets and artificial grain boundaries were observed. We then synthesized MoS₂ with unique structures on the MXene-coated substrate. As a result, flower-like MoS₂ structures grew on the MXene substrate, providing the MXene/MoS₂ structure with more binding sites, which was expected to enhance gas reactivity. The structure demonstrated excellent sensing performance particularly showing high sensitivity to H₂S among various gases. This heterostructure improves surface-to-volume ratios and enhances post-reaction recovery, addressing key limitations of conventional 2D materials in gas-sensing applications.

Experimental

Synthesis of MXene nanosheets

1 g of MAX (Ti₃AlC₂) powder was dispersed in a mixed solvent composed of HF, HCl, and deionized water in a 3 : 6 : 1 volume ratio for 24 hours. To separate the supernatant and obtain Ti₃C₂T_x nanosheets, the solution was adjusted to a pH of 6.0 and centrifuged at 12 000 rpm for 10 minutes. Subsequently, 50 mL of the Ti₃C₂T_x solution was allowed to react with 10 mL of LiCl solution for 4 hours. The intercalated Ti₃C₂T_x solution was then centrifuged with 150 mL of deionized water at 3000 rpm for 10 minutes to obtain the supernatant.

LB method for transfer of MXene

The MXene film was deposited *via* the LB method using the extracted suspension. The dispersed solution was poured into an LB trough (KSV Minimicro, Teflon trough with an active trough surface area of 273 cm², that is, $L\ 364 \times W\ 75 \times H\ 4\ \text{mm}^3$, and a dipping well of $L\ 20 \times W\ 56 \times H\ 60\ \text{mm}^3$; trough volume: 110 cm³) until the surface pressure reached 20 N mm⁻². The compression process was started using a compression speed of 3 mm min⁻¹ and continued until the surface pressure was reached at 30–35 mN m⁻¹. The film floating at the interface was transferred onto a SiO₂/Si substrate once using the vertical dipping method at a transfer rate of 1.0 mm min⁻¹ to adjust the thickness of MXene layers.

Synthesis of MXene/MoS₂ film

The MXene film was initially deposited onto a SiO₂/Si substrate using the LB method. MoS₂ layers were subsequently grown in a furnace equipped with a 1-inch quartz tube. In this process, a mixture of MoO₃ powder (Sigma-Aldrich, 99.97%, 25 g) was placed in an alumina boat positioned at the front of the furnace's heating zone, while the SiO₂/Si substrates were placed at the center of the heating zone. The reaction was initiated using an Ar/H₂S gas mixture (Seoul specialty gas, H₂S 10%, 47 L), along with Ar (99.99%, 47 L) and H₂ (99.99%, 47 L) as carrier gases. The furnace was first thermally annealed at 700 °C with a heating rate of 13.5 °C per minute for 50 minutes under a flow of 50 sccm of Ar. MoS₂ films were then grown on the MXene-coated substrate at 700 °C for 30 minutes using a layer-by-layer growth mode. During this synthesis, the flow rates of H₂, Ar, and Ar/H₂S gases were maintained at 50, 50, and 25 sccm, respectively. The reaction

pressure within the two-zone furnace was maintained at approximately 0.3 torr. After synthesis, the MXene/MoS₂ structure on the substrate was allowed to cool naturally by turning off the heat source, with the material cooling in ambient air.

Characterizations of the MXene/MoS₂

The morphologies of the synthesized MXene/MoS₂ were analyzed by field-emission scanning electron microscopy (FE-SEM, Hitachi, S-4700) and energy-dispersive X-ray spectroscopy (EDS). The crystallinity of MXene/MoS₂ crystals was investigated through transition electron microscopy (TEM, Titan Cube G2 60-300, FEI Company). Additionally, Raman spectroscopy (inVia Raman spectroscope, Renishaw) was employed to confirm the composition of the hybrid layer, using a 532 nm excitation wavelength laser.

Fabrication of gas sensors based MXene/MoS₂

To measure the gas responses of the device, Cr and Au (Cr 3 nm, Au 70 nm) were deposited as electrodes on the substrate using thermal evaporation. To evaluate the resistance change of the sensor, H₂, H₂S, NO, NO₂, NH₃, ethanol, and acetone gases were individually injected into the sensing chamber. The sensor was placed 2 cm away from the gas inlet, and measurements were conducted at a temperature of 250 °C with a relative humidity of 25%. The electrical characteristics of the sensor were recorded using a semiconductor parameter analyzer (Keithley-4200, Keithley Instruments, USA).

Results and discussion

To synthesize the MXene/MoS₂ layer, MXene nanosheets were prepared following previously work.³⁷ Briefly, HF combined with hydrochloric acid HCl was used for etching, followed by delamination using LiCl, a widely recognized method for producing high-quality MXene *via* alkaline cation intercalation and subsequent delamination (Fig. 1a). This process separated the accordion-like stacked MXene layers into individual nanosheets, enabling 2D epitaxial growth through van der Waals interactions. The resulting thin MXene nanosheets were then coated onto a substrate using the LB technique (Fig. 1b). The LB technique is commonly employed to fabricate ultrathin films from nanoparticles, nanowires, and nanosheets, offering high structural organization and reliability.^{38,39} The LB method stands out for producing monolayer films. This method is particularly effective for producing monolayer films, where molecules or particles are first dissolved in a volatile, water-immiscible solvent and spread onto the water surface. As the solvent evaporates, a monolayer forms and is compressed using movable barriers to control material density. For this study, the compression speed was set at a slow 3 mm min⁻¹, maintaining the surface pressure at 30–35 mN m⁻¹ to minimize overlap on the surface. Two successive transfers of MXene nanosheets were carried out to ensure uniform coverage. The sheet resistance of MXene and MXene/MoS₂ was measured, revealing that MXene nanosheets exhibited a sheet resistance of several hundred ohms/sq. after a single transfer onto an SiO₂/Si substrate using



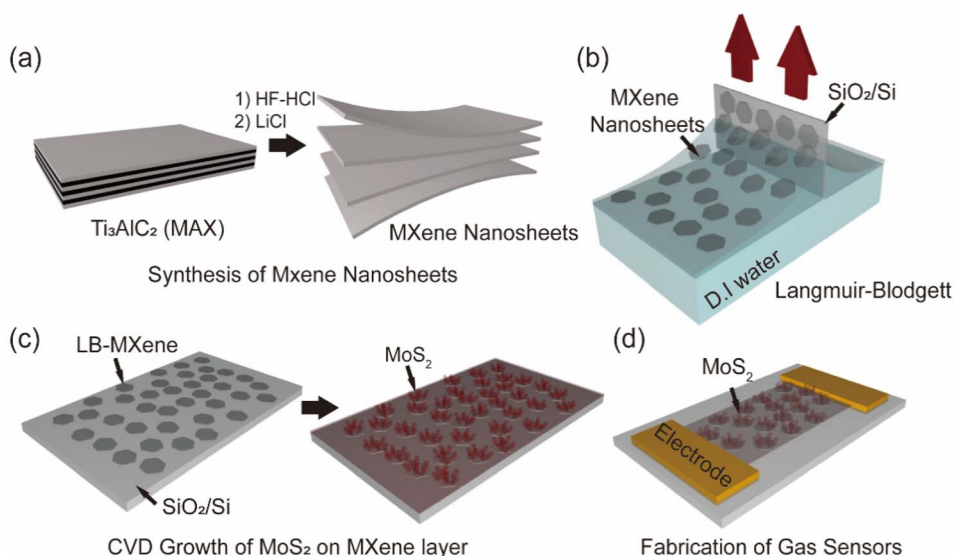


Fig. 1 Schematic illustration of the synthesis of MXene/MoS₂. (a) Preparation of MXene nanosheets from MAX phase, (b) thin layer formation of MXene on SiO₂/Si substrate using LB technique. (c) Growth of MoS₂ on LB-MXene, and (d) fabrication of LB-MXene/MoS₂ based gas sensor.

the LB technique (Fig S1†). The sheet resistance was found to decrease with ν . A total of two MXene nanosheet transfers were performed using this technique. Fig. 1c illustrates the uniform synthesis of MoS₂ on the MXene nanosheets *via* CVD. During synthesis, the inert Ar and H₂ atmosphere effectively minimized the oxidation of MXene nanosheets to TiO₂, although partial oxidation of Ti₃C₂T_x was unavoidable during the LB process. Finally, as shown in Fig. 1d, a resistive-type gas sensor was fabricated by depositing Au and Cr electrodes onto the SiO₂/Si substrate with the synthesized MXene/MoS₂ layer using thermal

evaporation. Our novel method fabricates thin and uniform MXene sheets, followed by the synthesis of flower-shaped MoS₂ *via* CVD, which is not only uniform to the MXene nanosheets but also offer more gas adsorption sites than either individual material, and is expected to be applied as a gas sensor.

To analyze the morphology of the MoS₂ on MXene layers, we performed FE-SEM were checked at each stage of the synthesis of the composite material. As shown in Fig. 2a, the image depicts the substrate with MXene nanosheets transferred *via* the LB method. Although some gaps are present, the MXene

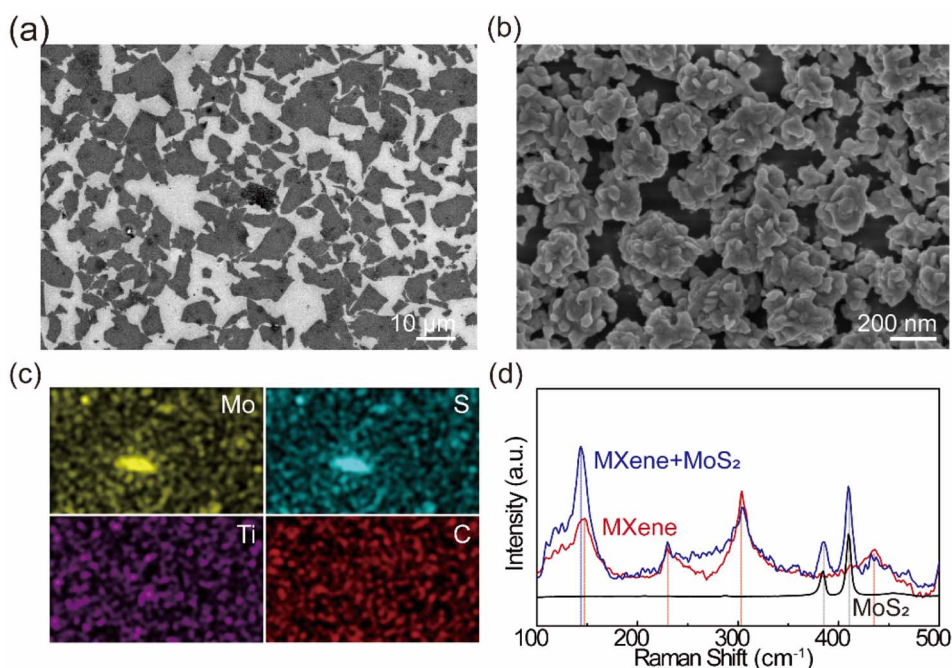


Fig. 2 Morphology and structural analysis of the MXene/MoS₂. SEM image of (a) the LB-MXene nanosheets onto a SiO₂/Si substrate, (b) the synthesized MoS₂ on LB-MXene, (c) EDS mapping images of MXene/MoS₂, (d) Raman spectrum of MoS₂, MXene, and MXene/MoS₂.



nanosheets transferred onto the substrate formed a monolayer without overlapping, consistent with the characteristics of the LB technique. As the MXene nanosheets were transferred onto the SiO₂/Si substrate using the LB method, they formed a very thin layer, allowing the Si peak at 69.26° to be observed clearly (Fig. S2†). This confirmed that the LB technique successfully transferred the MXene nanosheets onto the substrate. Subsequently, MoS₂ was grown using a CVD process with MoO₃ powder and H₂S gas. When we investigated the roughness of the MoS₂ synthesized on LB-MXene (Fig. S3†), we found that the MXene nanosheets were not laying in the same orientation, resulting in the synthesis of MoS₂ on MXene with random morphology and roughness. As shown in Fig. 2b, MoS₂ grew uniformly across the substrate, with nanoflower-like structures vertically grown on top of the MXene nanosheets. When MoS₂ was grown on the substrate with transferred MXene nanosheets, MoS₂ grew across the entire surface, but particularly on the MXene nanosheets, it grew vertically, forming a nanoflower-like morphology. This provided more adsorption sites compared to pristine MXene, suggesting better performance as a gas sensor. The results (Fig. 2c) indicated the significant elements for the MXene/MoS₂ (Ti, C, Mo, and S). It was confirmed that each of the main elements is uniformly distributed. As shown in Fig. 2d, the characteristic peaks of pristine MoS₂, the E_{2g} peak at 384.66 cm⁻¹ and the A_{1g} peak at 409.76 cm⁻¹, were also observed after the synthesis of MXene. The distance between the E_{2g} peak and the A_{1g} peak of MoS₂ was 25.12 cm⁻¹, indicating the growth of multilayer MoS₂. Additionally, the peak observed at 147.55 cm⁻¹ in pristine MXene shifted by approximately 3.5 cm⁻¹ to 143.85 cm⁻¹ after the growth of MoS₂, with a corresponding increase in intensity. This is a typical E_{2g} peak of TiO₂, and it is presumed that, as a portion of MXene was oxidized into MXene-derived TiO₂ during the growth of MoS₂, stress or defects generated during the oxidation process affected the local structure of the material, causing a shift in the Raman peak and an increase in intensity due to improved crystallinity. Raman analysis (Fig. S4†) was conducted at eight randomly designated sites, revealing the presence of both MoS₂ and MXene peaks at each site. This confirmed not only the uniform distribution of the main elements but also consistent chemical bonding between MoS₂ and MXene. Therefore, we present an approach to synthesize homogeneous MoS₂ using a simple method.

To evaluate the gas sensing properties of the MXene/MoS₂-based sensor, we compared the gas reactivity of pristine MoS₂ with that of the MXene/MoS₂ heterostructure (Fig. 3a and S5†).

The gas response of the sensor is represented by *R*, and the corresponding reaction equation is as follows:

$$\text{Gas response } (R) = R_a/R_g \text{ or } R_g/R_a.$$

Both MXene and MoS₂ are generally recognized as n-type materials, which makes them well-suited for detecting oxidative gases. A notable improvement in reactivity towards reducing gases, such as H₂S and H₂, was observed with the formation of the MXene/MoS₂ heterostructure. Furthermore,

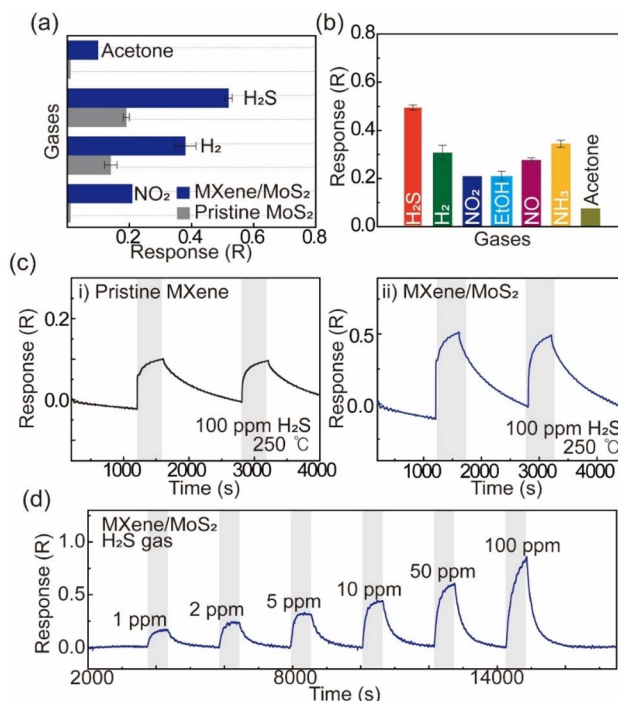


Fig. 3 Gas sensing properties of the MXene/MoS₂ gas sensor. (a) Comparisons of response value between pristine MXene and MXene/MoS₂ about various gases. The gas responses of MXene/MoS₂ at various gases (H₂S, H₂, NO₂, ethanol, NO, NH₃, and acetone) at 100 ppm, (b) the gas responses of MXene/MoS₂ at various gases at 100 ppm, (c) the dynamic response curve to H₂S gas response of (i) the pristine MXene and (ii) the MXene/MoS₂ based gas sensor, and (d) H₂S Gas responses of the MXene/MoS₂ based gas sensor at various concentration of H₂S (100 ppm to 1 ppm). All gas responses were measured in a dry atmosphere.

the sensitivity to oxidizing gases, particularly NO₂, was significantly enhanced, suggesting that the n-type/n-type heterostructure is highly effective in improving gas sensing performance. Fig. 3b and S6 in ESI† presents the response of the MXene/MoS₂ gas sensor to various gases (H₂S, H₂, NO₂, ethanol, NO, NH₃, and acetone), with the highest response observed for H₂S. Fig. 3c shows the dynamic response curve for 100 ppm of H₂S, where the MXene/MoS₂ heterostructure exhibits approximately a five-fold increase in sensitivity compared to the pristine MXene sensor. The slightly lower gas response in the second cycle is related to the gas desorption time on the surface of the MXene/MoS₂. We also conducted a follow-up test on the MXene/MoS₂ device a week later, which demonstrated a stable gas response of approximately 0.50 for H₂S, confirming its long-term stability (Fig. S7†). Furthermore, as shown in Fig. 3d, the MXene/MoS₂ gas sensor demonstrated a notable gas response of 0.17 even at a low concentration of 1 ppm of H₂S. Based on the limit of detection (LOD) definition defined by the International Union of Pure and Applied Chemistry (IUPAC), the gas sensor demonstrated the ability to detect H₂S at concentrations as low as 0.87 ppb, according to the calculated LOD as shown in Fig. S8.† These results suggest that the uniform vertical growth of MoS₂ on MXene contributes to the enhancement of gas sensing performance by providing more adsorption sites,



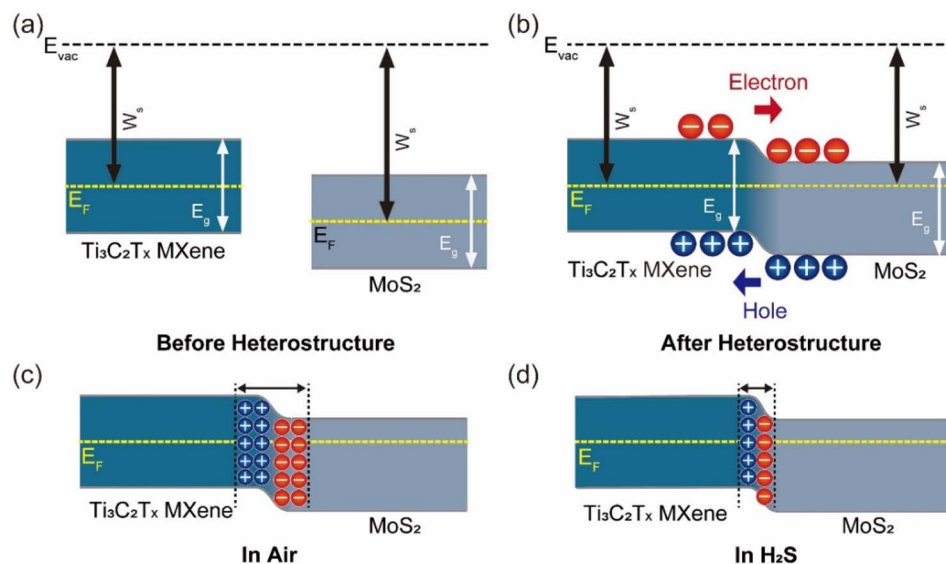
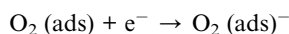
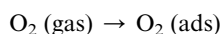


Fig. 4 Band diagram of chemi-resistive gas sensor based on MXene/MoS₂ layer. Band diagrams before (a) and after (b) forming the heterostructure between MXene and MoS₂. Band diagram under air (c) and H₂S (d) injection.

improving gas sensing performance. Therefore, we propose that this method offers a promising solution to overcome the limitations in surface functionalization commonly faced by materials such as MXene and MoS₂.

To understand the enhanced gas response toward H₂S compared to pristine MXene, we studied the mechanism of the MXene/MoS₂ heterostructure. As illustrated in Fig. 4a and b, when MXene and MoS₂ exist independently, each material maintains its respective Fermi level, when a heterojunction is formed between MXene and MoS₂, band bending occurs due to the alignment of the Fermi levels of the two materials. This results in the bending of the conduction band and valence band. When the MXene/MoS₂ heterojunction is exposed to oxygen, oxygen ions are adsorbed on the surface, forming a depletion layer (Fig. 4c). Upon the introduction of H₂S, interactions between H₂S molecules and O₂ (ads) cause electrons to transfer to the conduction band of MoS₂, reducing the number of holes in MXene (Fig. 4d). This process leads to the re-ionization of electron-hole pairs, which increases the number of free electrons, further reducing the width of the depletion layer. Consequently, this leads to a decrease in resistance, which directly reflects the enhanced responsiveness of the resistive gas sensor.

The reaction equations related to this are as follows:



Also, we expected that the MXene-derived TiO₂ provides more active sites compared to pristine MXene, facilitating the adsorption of more gas molecules on the surface, which in turn

contributes to the improved gas sensing performance.^{40,41} This synergy between MXene and MoS₂ enhances the overall gas sensing mechanism by promoting more efficient electron transfer and gas molecule interaction at the heterojunction.

Conclusion

In conclusion, we successfully achieved uniform transfer of MXene nanosheets onto a substrate using the LB technique. Following this, flower-like MoS₂ was uniformly grown on the MXene-coated substrate using CVD, with selective vertical growth observed on the MXene nanosheets. In terms of gas-sensing performance, pristine MXene exhibited a gas response of 0.1 to H₂S, whereas the MXene/MoS₂ heterostructure showed a markedly enhanced response of 0.5, representing approximately five times greater sensitivity. This improvement is attributed to the formation of a heterojunction between MXene and MoS₂, which reduced the depletion layer and expanded the region for free movement of electrons and holes. The enhanced electron mobility facilitated more efficient gas detection, while the increased conductivity addressed the slow resistance recovery typically seen in hydrogen-based gas sensors. Additionally, the sensor exhibited the highest gas response to H₂S among various gases tested. Thus, this novel synthesis approach, combining the uniform transfer of MXene *via* the LB technique and the growth of MoS₂ through CVD, not only enables the simple preparation of heterostructured materials but also enhances the gas-sensing performance by creating an n-type/n-type composite, which improves the detection of the target gas.

Data availability

The data supporting this article have been included as part of the ESI.†



Author contributions

Jae Hyuk Shin: investigation, data curation, writing – original draft. Su Hun Jo: investigation, data curation, writing – editing. Hyejin Rhyu: investigation. Chanwon Park: data curation. Myung Hyun Kang: data curation, supervision, writing – review & editing. Wooseok Song: validation. Sun Sook Lee: validation. Jongsun Lim: validation. Sung Myung: conceptualization, supervision, writing – review & editing.

Conflicts of interest

There are no conflicts to declare.

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